Search Notes



Application/Cont	rol No.
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10551793

Applicant(s)/Patent Under Reexamination

KANEGASAKI ET AL.

Examiner

HEE-YONG KIM

Art Unit

2621

SEARCHED

Class	Subclass	Date	Examiner
348	79	7/1/2010	H.K

SEARCH NOTES	SE	AR	Cŀ	1 N	10	TES
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Search Notes	Date	Examiner
microscope and (mirror with target)	6/29/2010	H.K
microscope and (mirror with target) and (vertcial\$2 light)	6/29	H.K
microscope and (aperture with wavelength with distance)	6/29	H.K
microscope and ((numerical aperture) near2 (light and lens))	6/29	H.K
reflect\$3 with (coat\$3 or bond\$3 or superimpos\$3)	6/30	H.K
((reflect\$4 (layer or plane) with (bond\$3)) with (taret or sample)	6/30	H.K
focal depth with distance with reflect\$3 (plane or surface)	7/1	H.K
field parameter with numerical aperture	7/1	H.K
NPL search (focal depth and wavelength and numerical aperture)	7/1	H.K
Inventor Search at Edan	7/1	H.K

	INTERFERENCE SEAF	RCH	
Class	Subclass	Date	Examiner

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